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PATENT
Customer No. 22,852
Attorney Docket No. 04329.2335

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Tokuhisa OHIWA, et al.) Group Art Unit: 2823
)
Serial No.: 09/604,724) Examiner: Maldonado, Julio J.
)
Filed: June 28, 2000)
)
For: HIGH PRECISION PATTERN)
FORMING METHOD OF)
MANUFACTURING A)
SEMICONDUCTOR DEVICE (AS)
AMENDED))

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

AMENDMENT

In reply to the Office Action dated January 28, 2002, with a period for response
extending through April 29, 2002 (April 28th being a Sunday), please amend the application as
follows:

IN THE TITLE:

On page 1, please replace the title at line 2 with the following title: HIGH PRECISION
PATTERN FORMING METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE.

IN THE CLAIMS:

Please add new claims 21 – 23 as follows:

FINNEGAN
HENDERSON
FARABOW
GARRETT &
DUNNER LLP

1300 I Street, NW
Washington, DC 20005
202.408.4000
Fax 202.408.4400
www.finnegan.com

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01 FC:103
02 FC:102

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